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APPLICATION NO. 10/550381

APPLICANT Ailten, David of al. FILING DATE April 02, 2004

Group 1617

			U.S. PA	TENT DOCUMENTS				
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	AP	OTHER DOG	UMENTS (In	cluding Author, Title, Date, P	ertinent pages, i	ic.)		-
	AP	Zarnowski, Tomasz e Common Anticonvuls Pharmacology And P	t al., "NBQX-A ant Drugs Aga harmacy, Vol.	Selective AMPA Antago inst Maximal Electroshot 44, ppp 258-259 (1992).	nist Enhances k in Mioe", Po	Antiepileptic lish Journal c	of	rties of
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